

Light harvesting properties of Graphene Oxide Nanoribbons

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Solar Powered Nano-Sensors
for data acquisition and surveying in remote areas

*National and International Research Alliances Program
Queensland Government Smart Futures Fund 2009-2012*

QUT, CQU, Uni Roma Tor Vergata, Uni Brescia, Dyesol

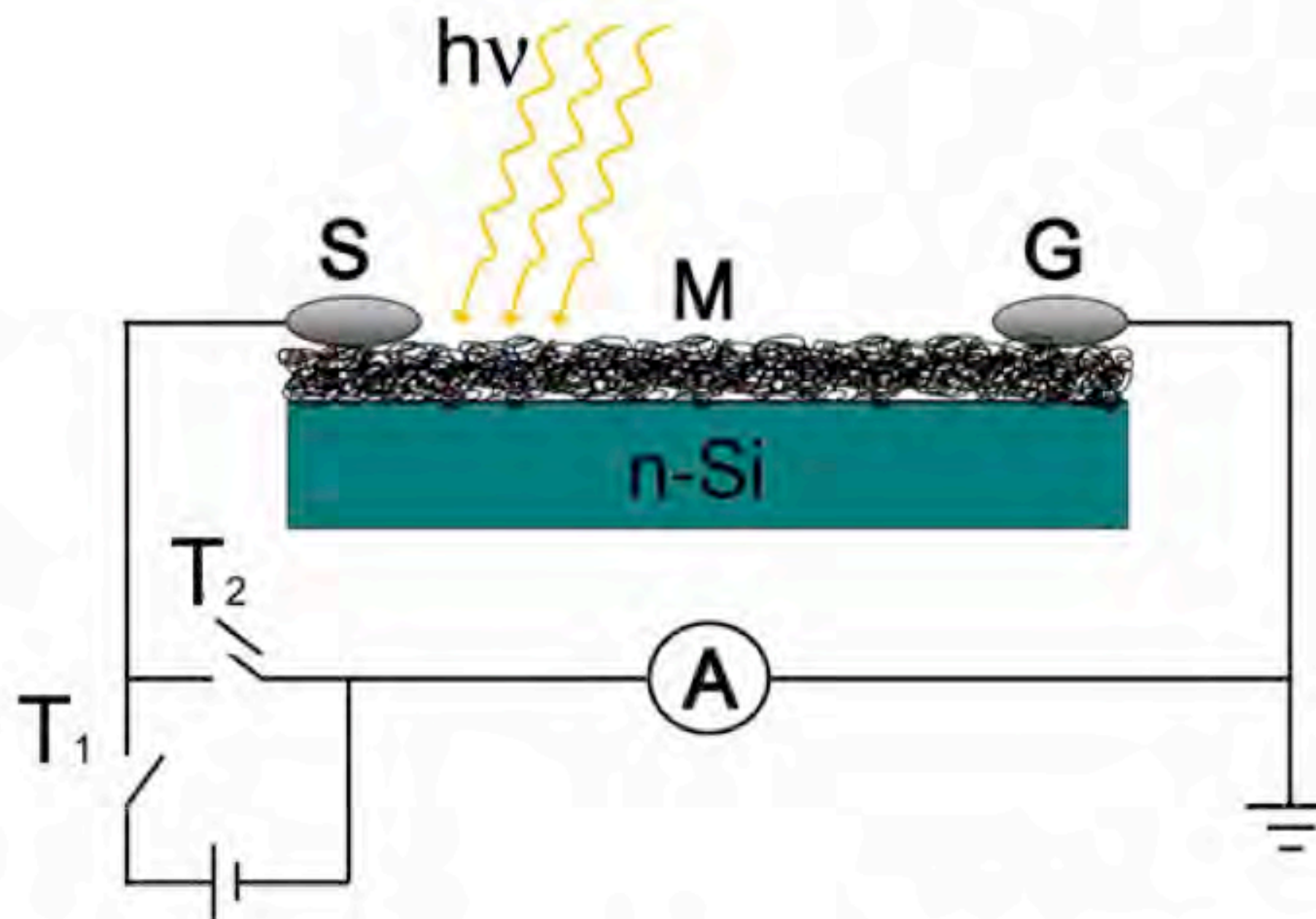


Outline

- “State of the art” of carbon nanotubes and graphene in solar energy conversion
- Production of graphene oxide nanoribbons
- Realization of graphene oxide nanoribbons devices
- Electro-optical characterization of the devices
- Conclusions

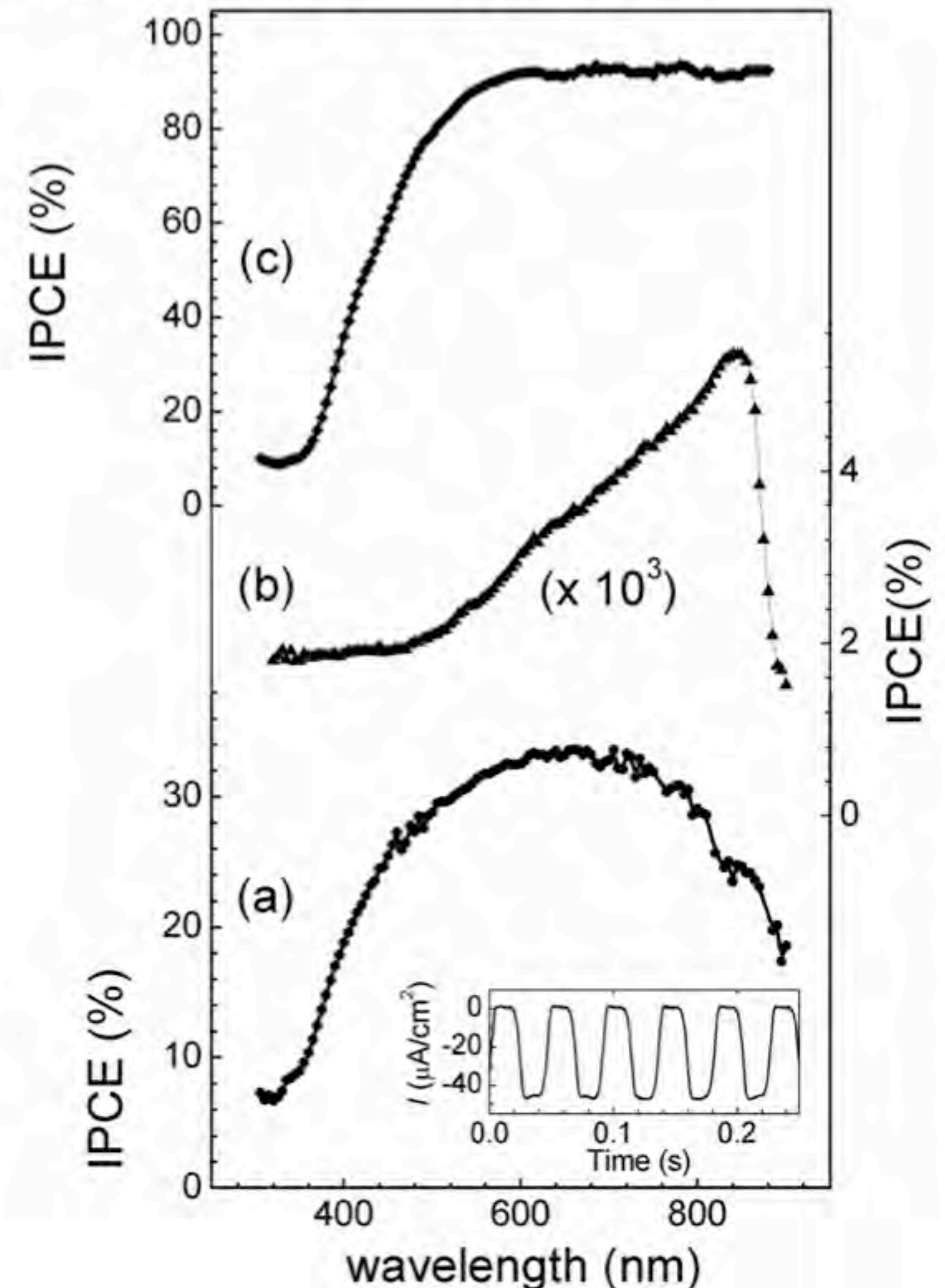
MWCNT/Si PV device

Multiple Schottky junctions between metallic CNT and semiconducting Si

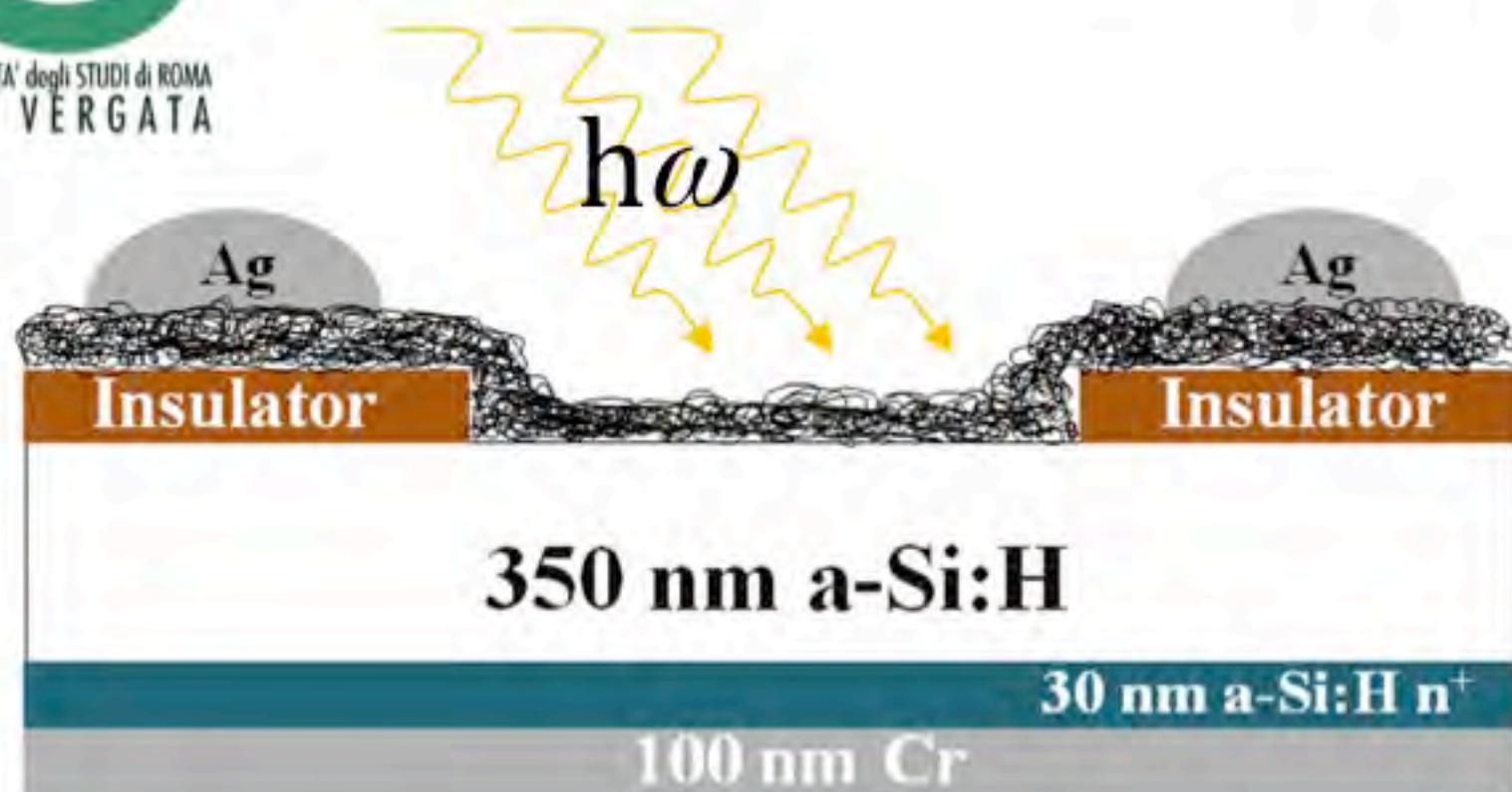


P. Castrucci et al. *Nanotechnology* 22 (2011) 115701

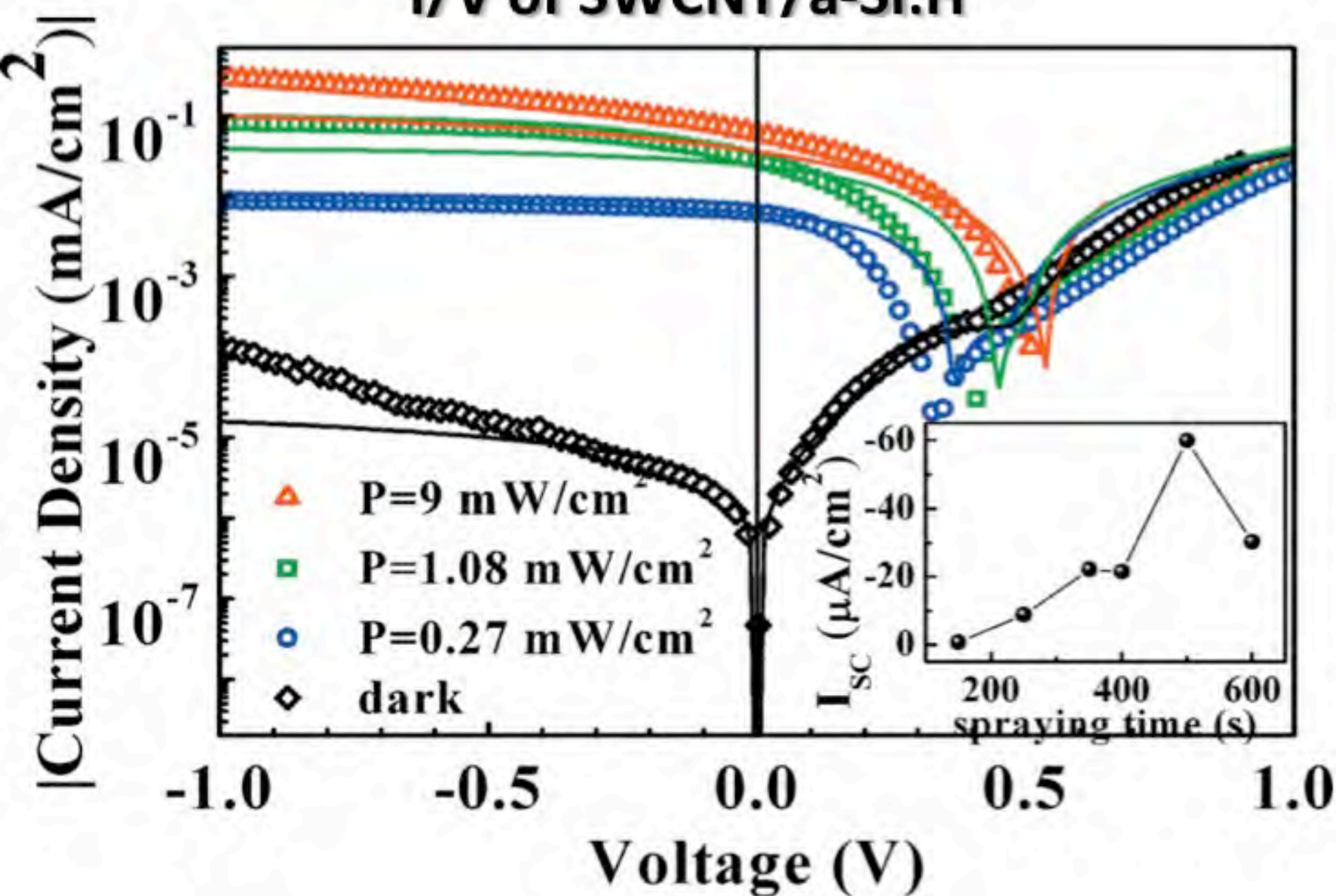
Among top downloaded papers in 2011!



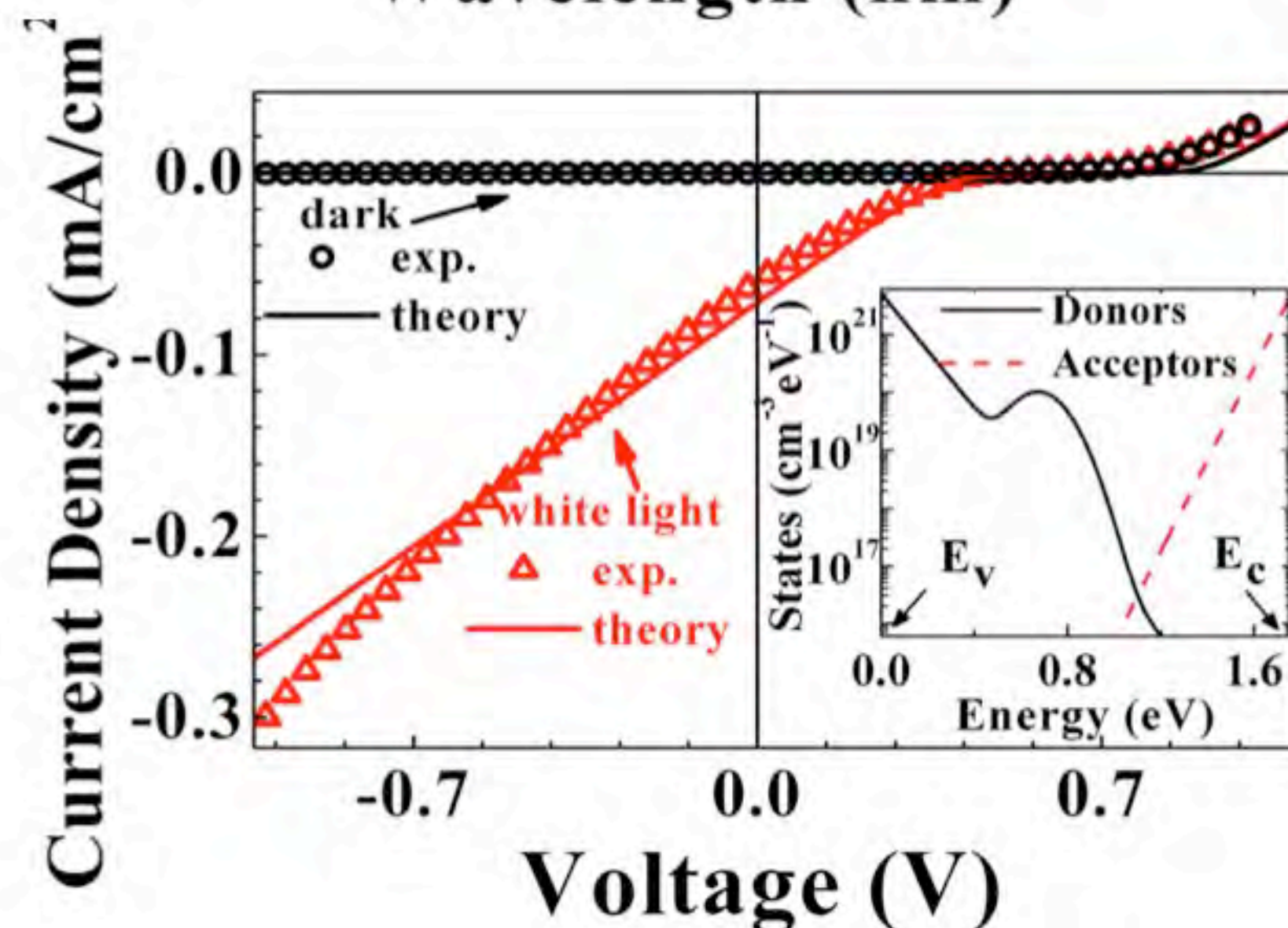
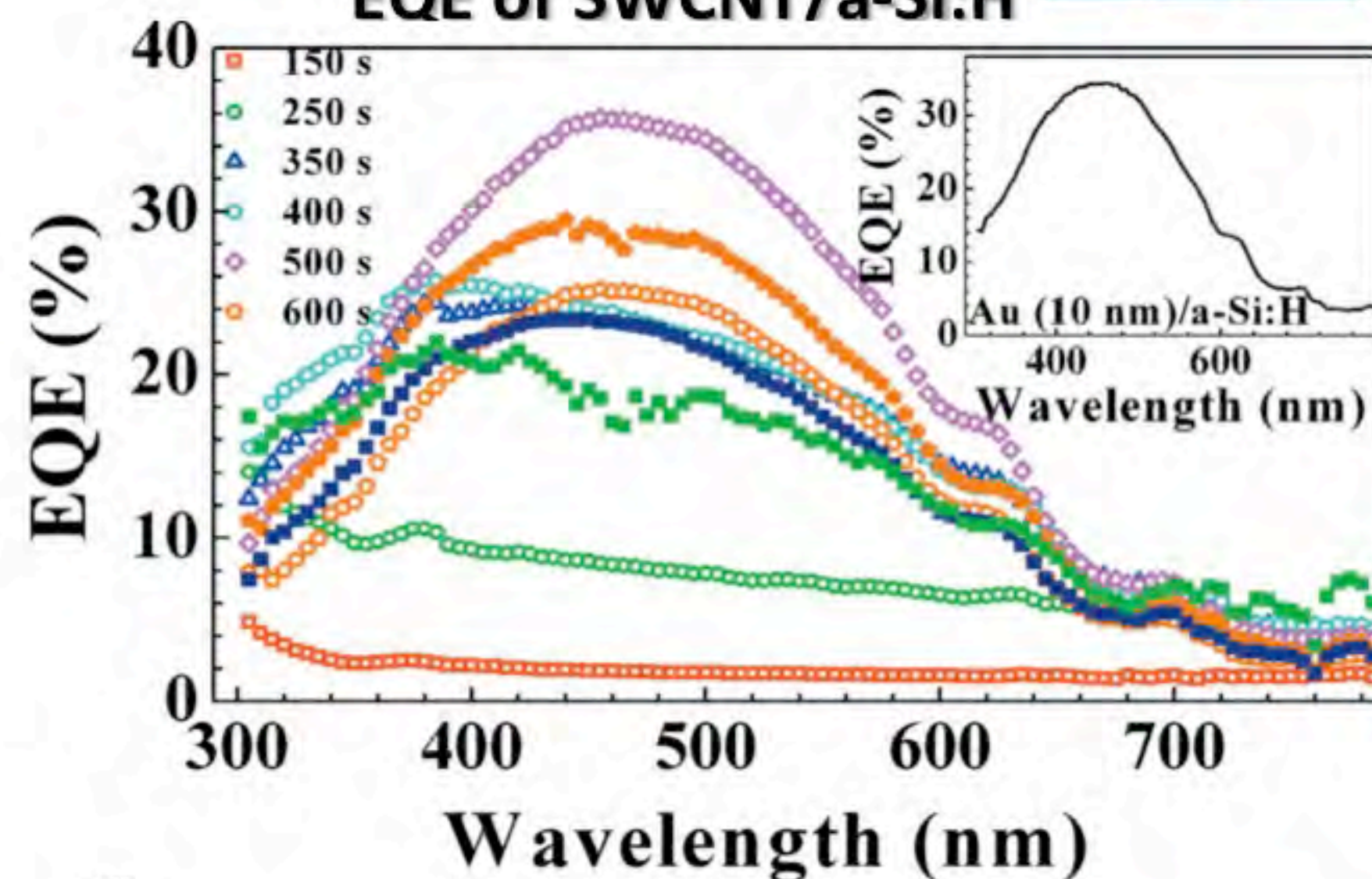
SWCNT/amorphous Si (a-Si:H)



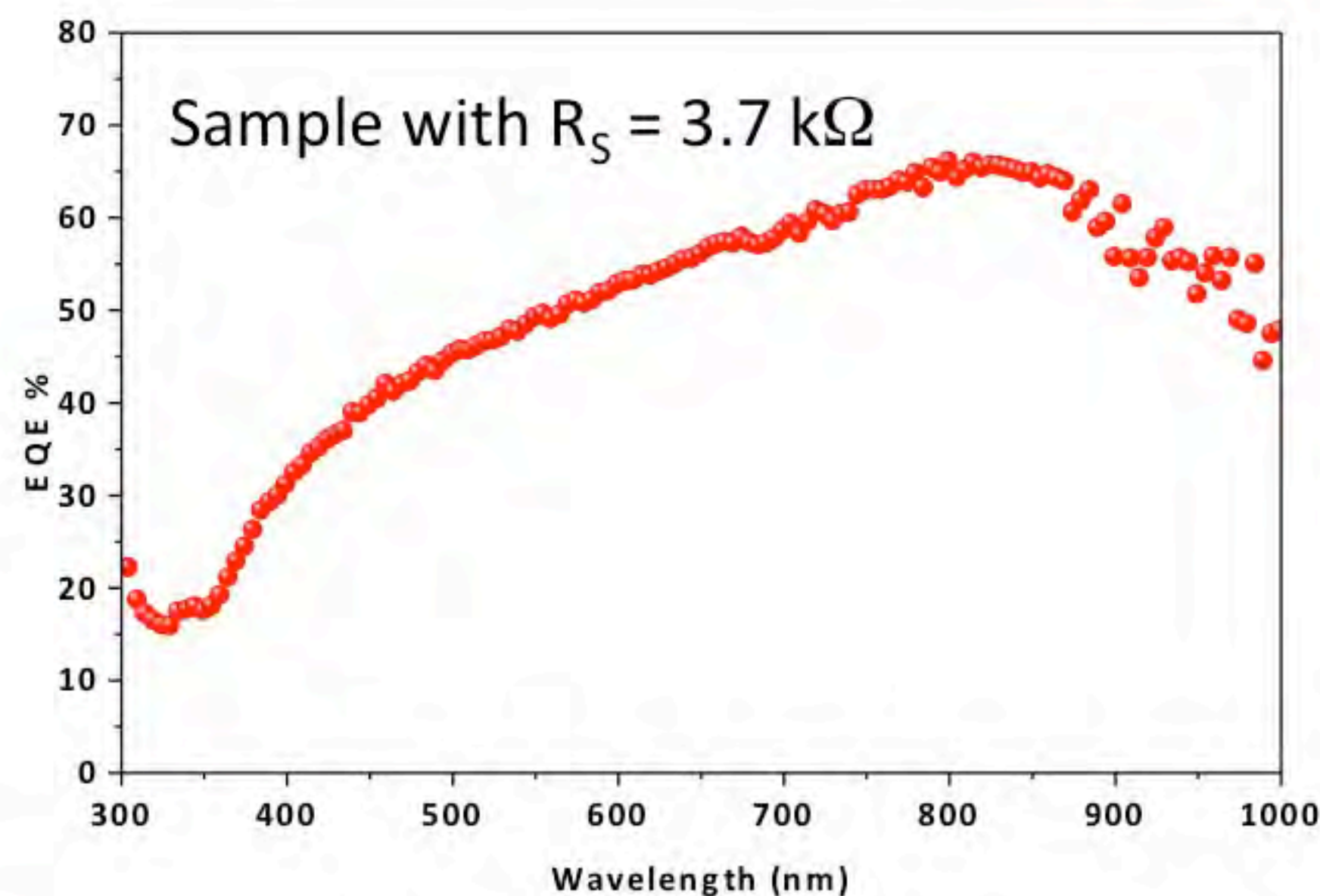
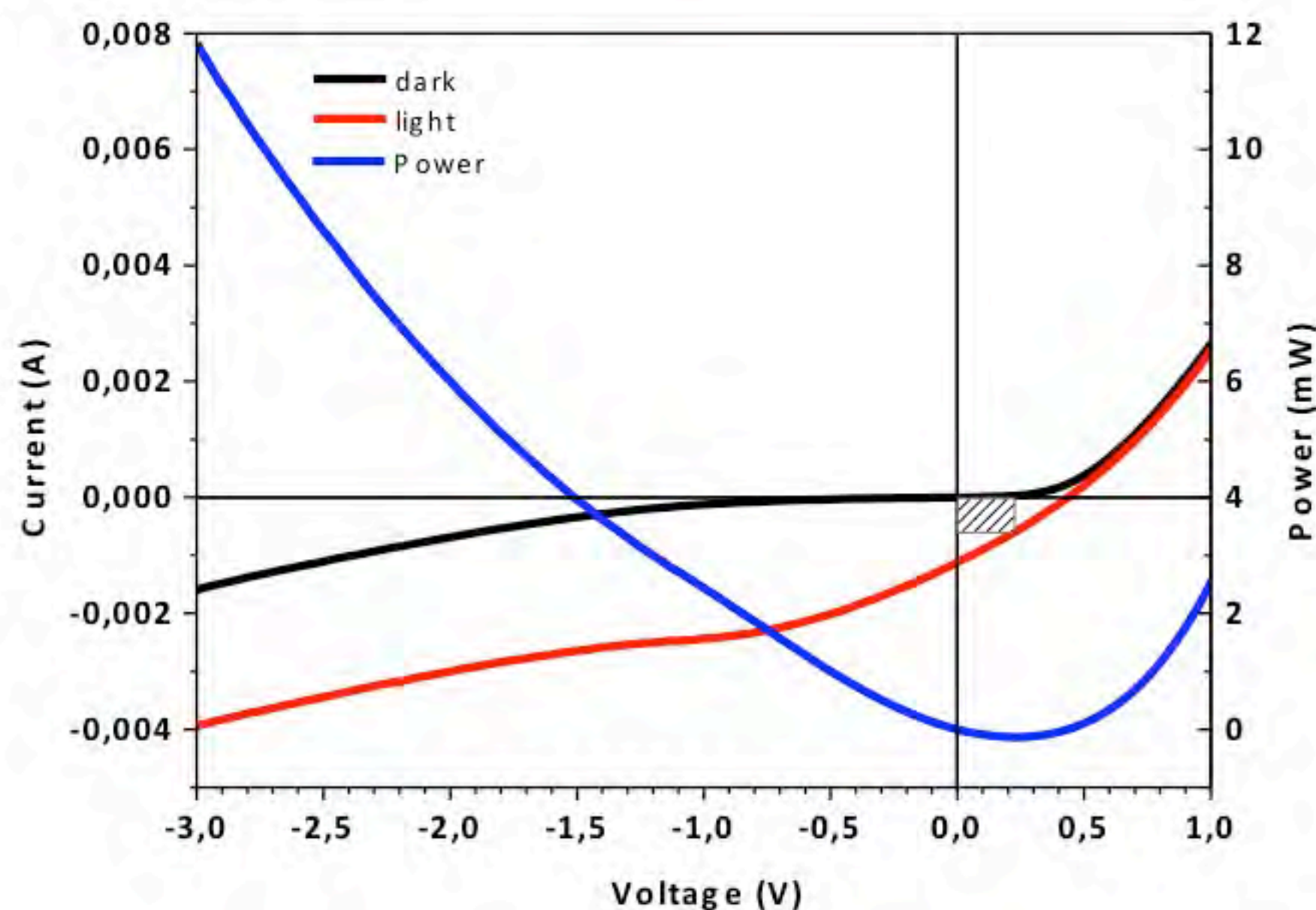
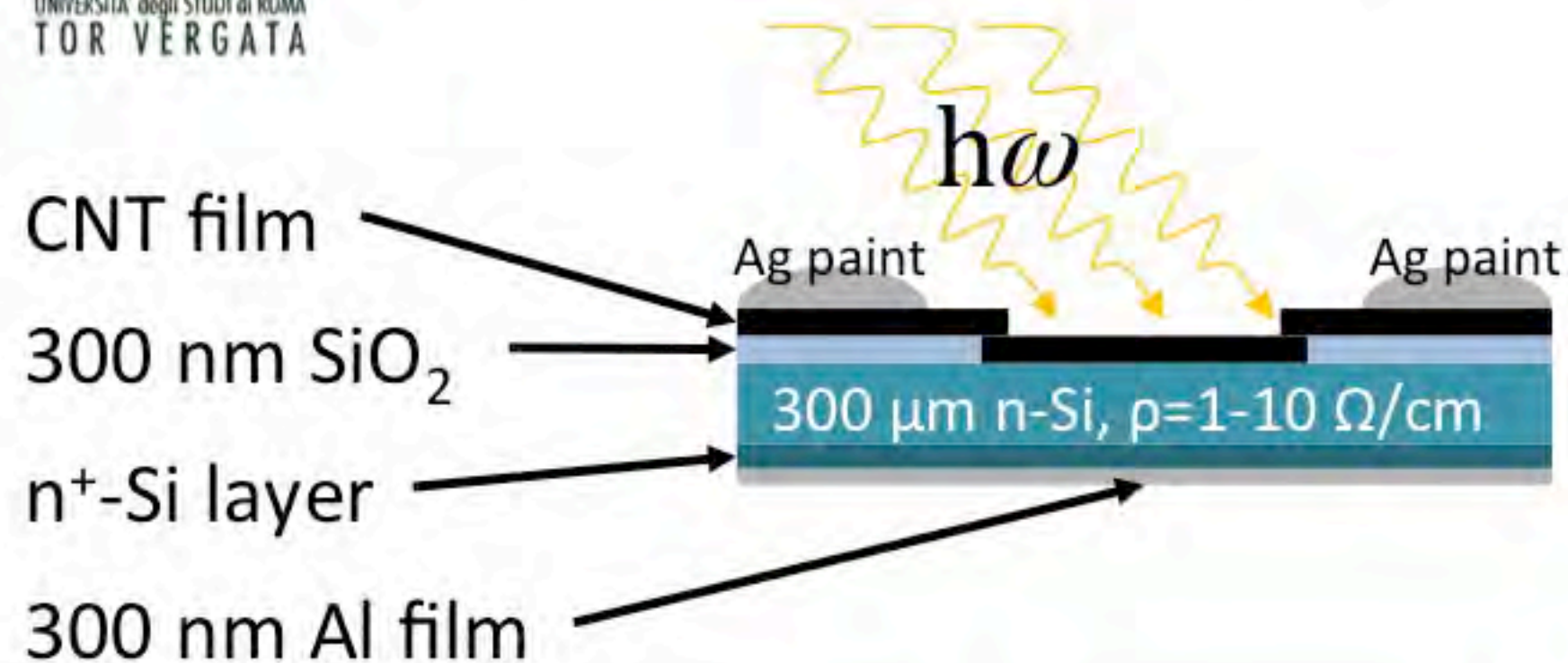
I/V of SWCNT/a-Si:H



EQE of SWCNT/a-Si:H



SWCNT on Si (ohmic contact)



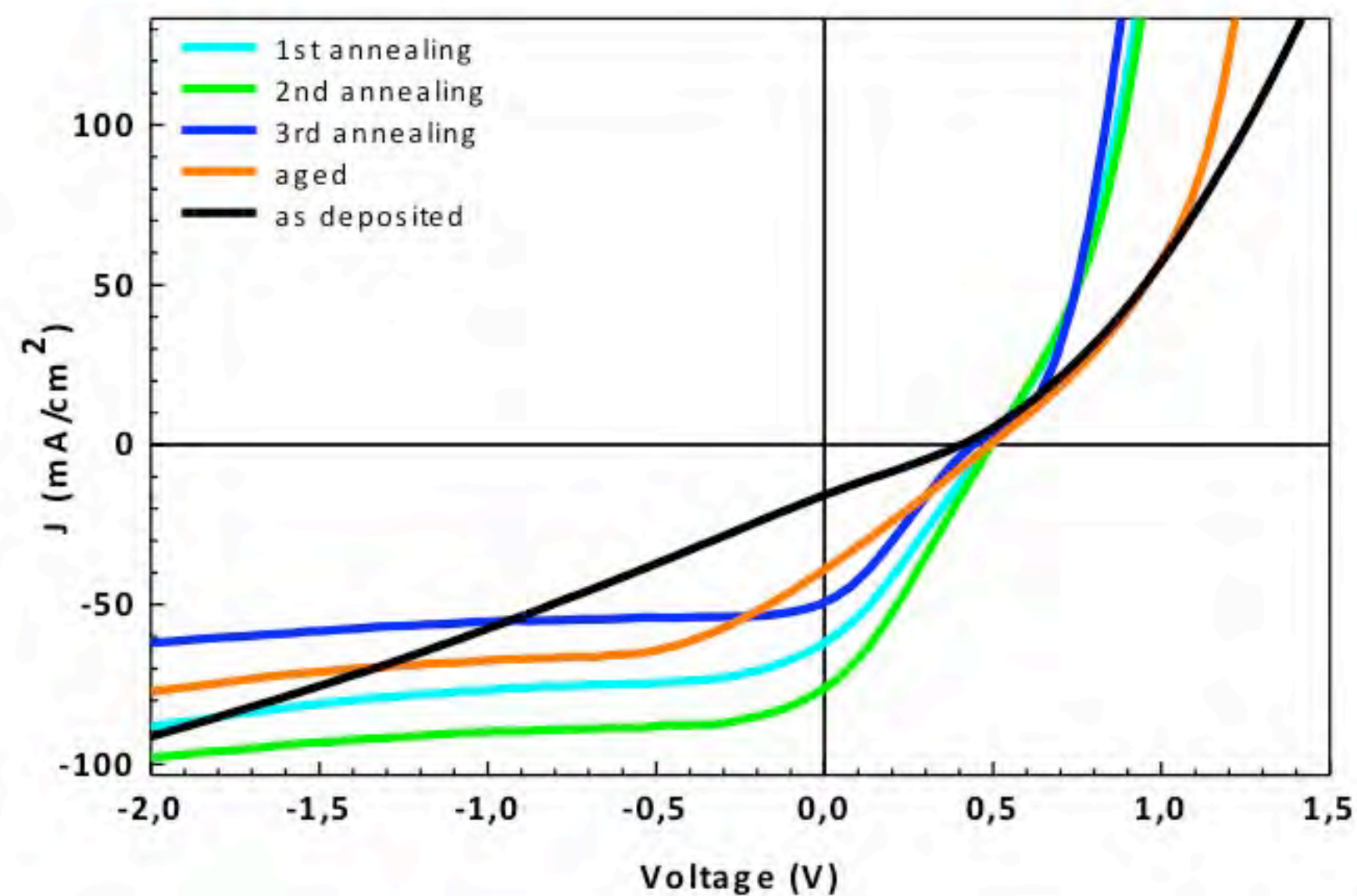
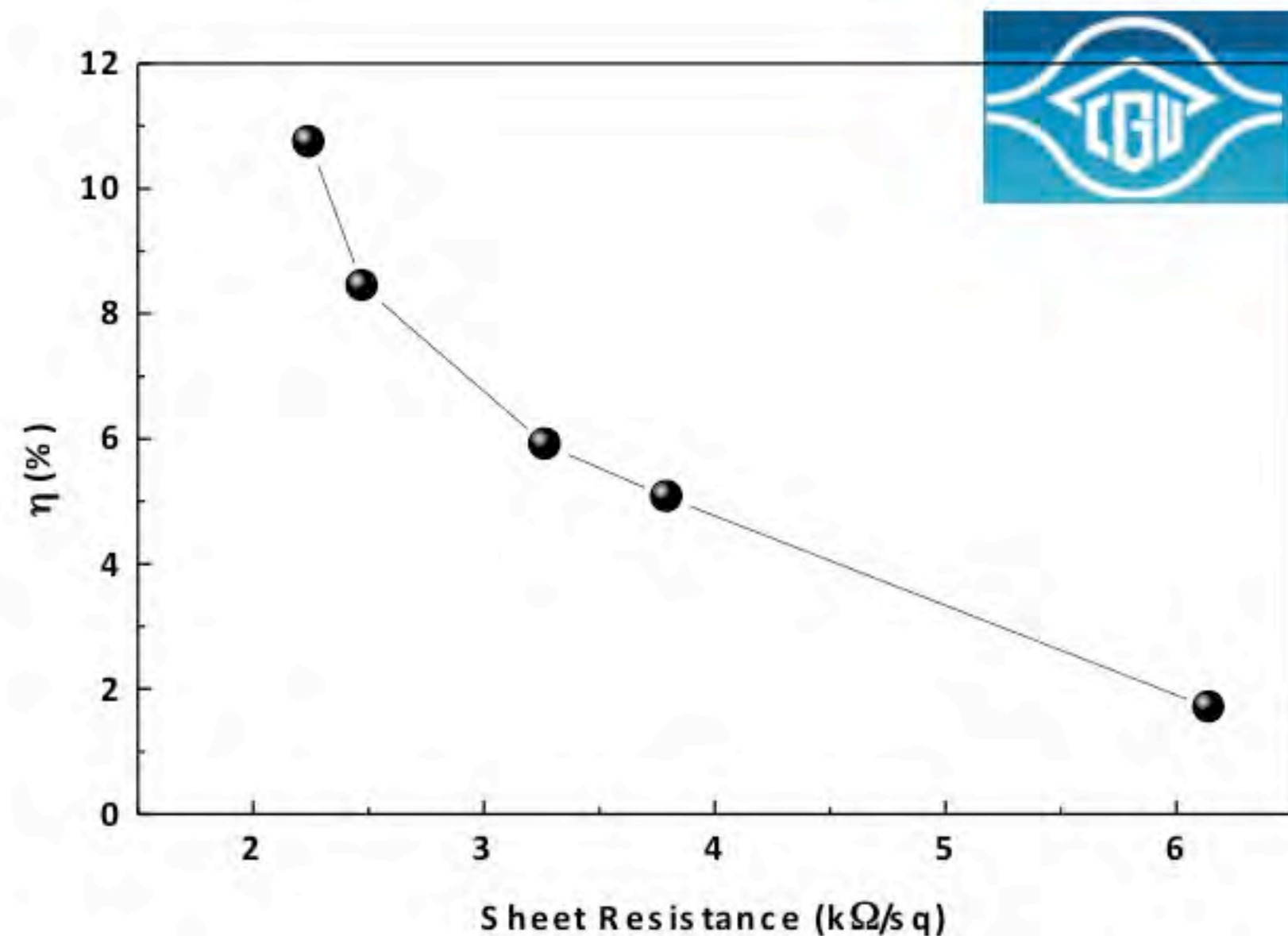
$$FF = \frac{V_{mp} I_{mp}}{V_{oc} I_{sc}} = 0.27$$

$$\eta = \frac{P_m}{E \times A_c} \approx 3\%$$

After annealing

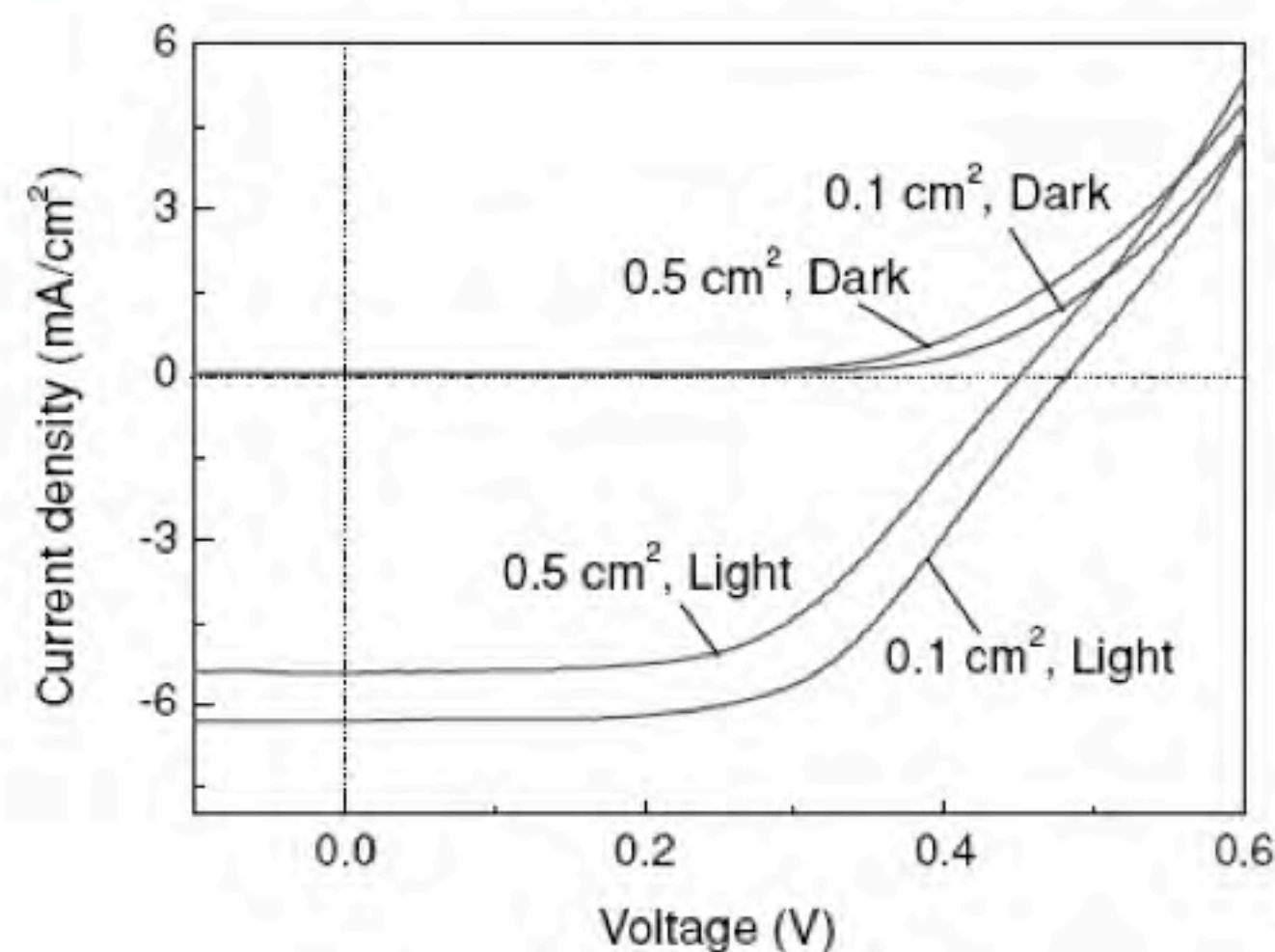
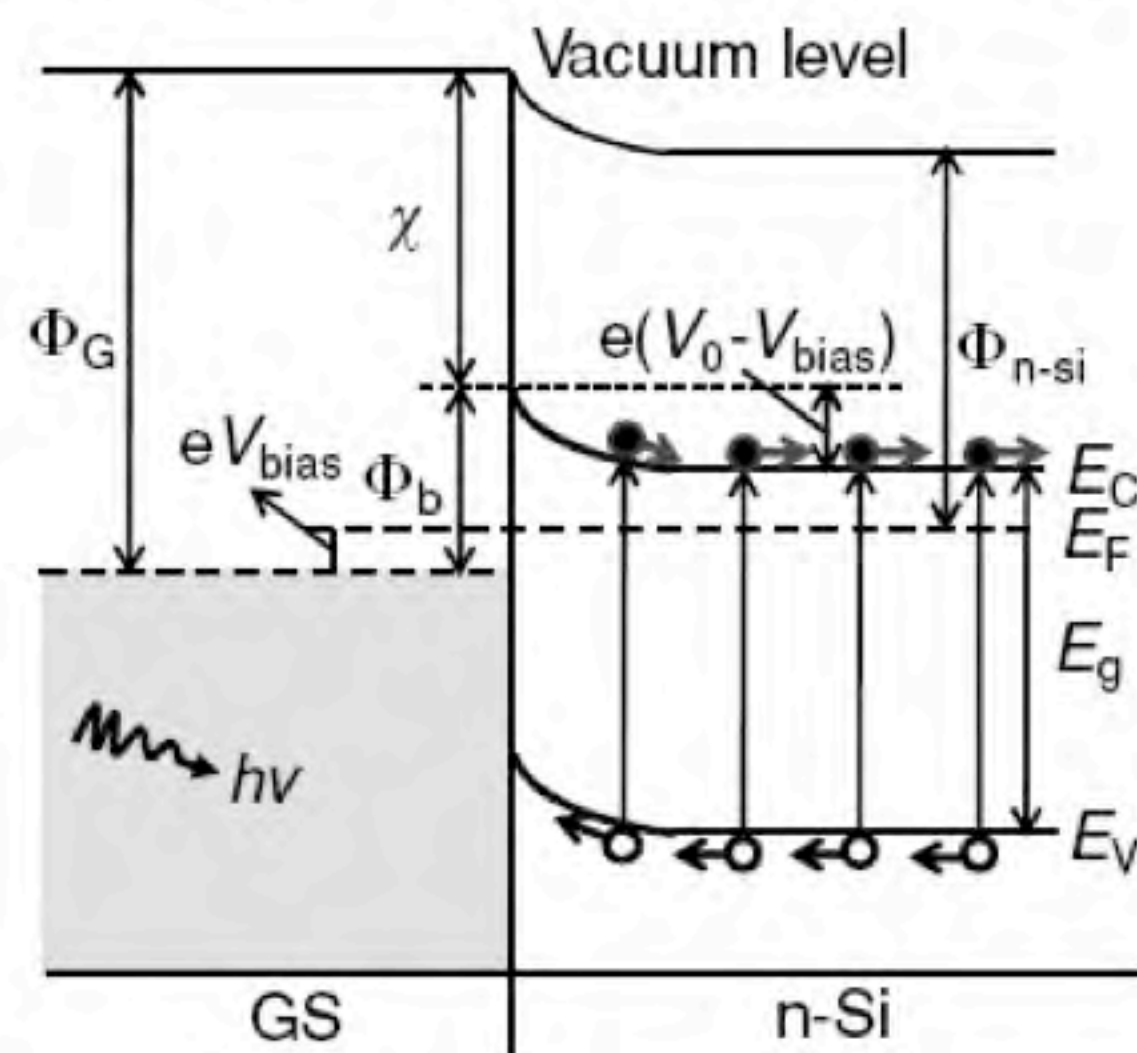
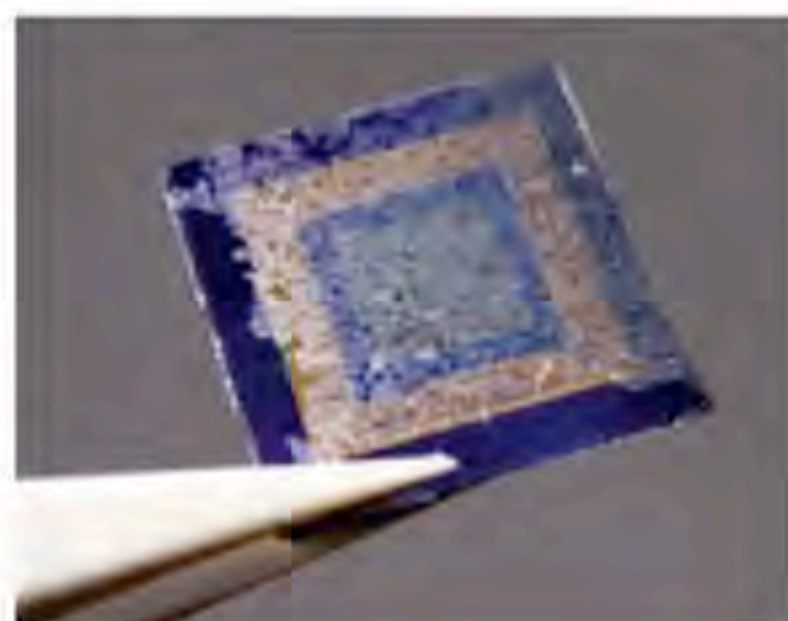
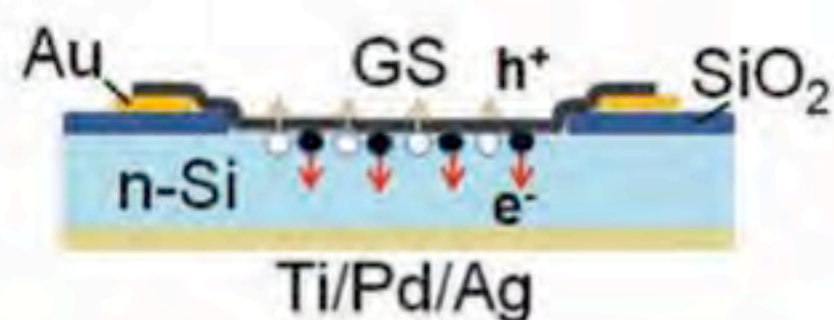
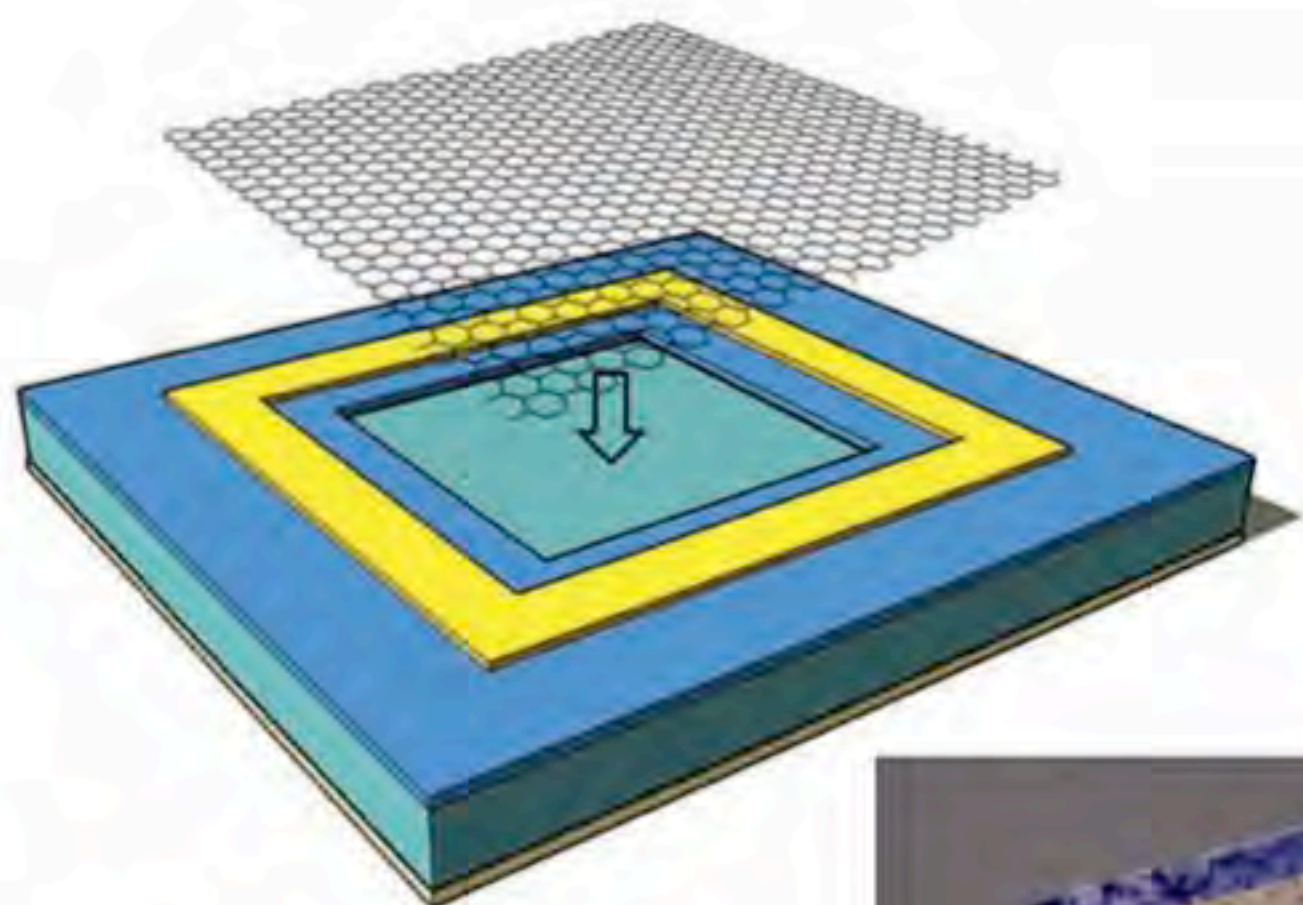
Sample with $R_s = 3.7 \text{ k}\Omega$

	R (k Ω)	R _{sheet} (k Ω)	FF	η (%)
As deposited	3.725	6.15	0.26	1.7
Aged (15 gg)	2.3	3.8	0.26	5.06
1 st Ann. @ T=280°C	1.5	2.5	0.28	8.43
2 nd Ann. @ T=280°C	1.36	2.2	0.29	10.73
3 rd Ann. @ T=280°C	1.98	3.3	0.27	5.90



Graphene/Si solar cell

Schottky junction between metallic graphene and semiconducting Si



X. Li et al. *Adv. Mater.* 22 (2010) 2743

Synthesis of Graphene Oxide Nanoribbons (GONR)

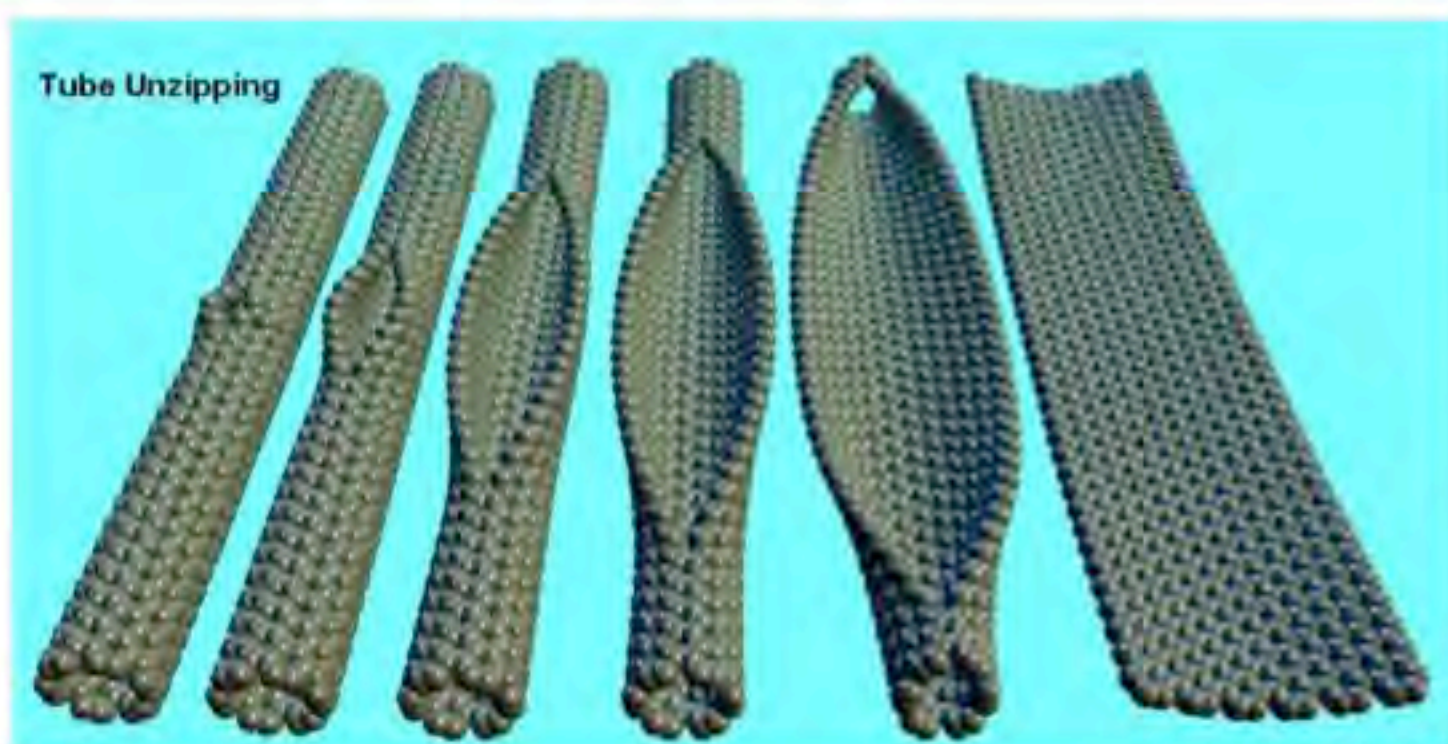
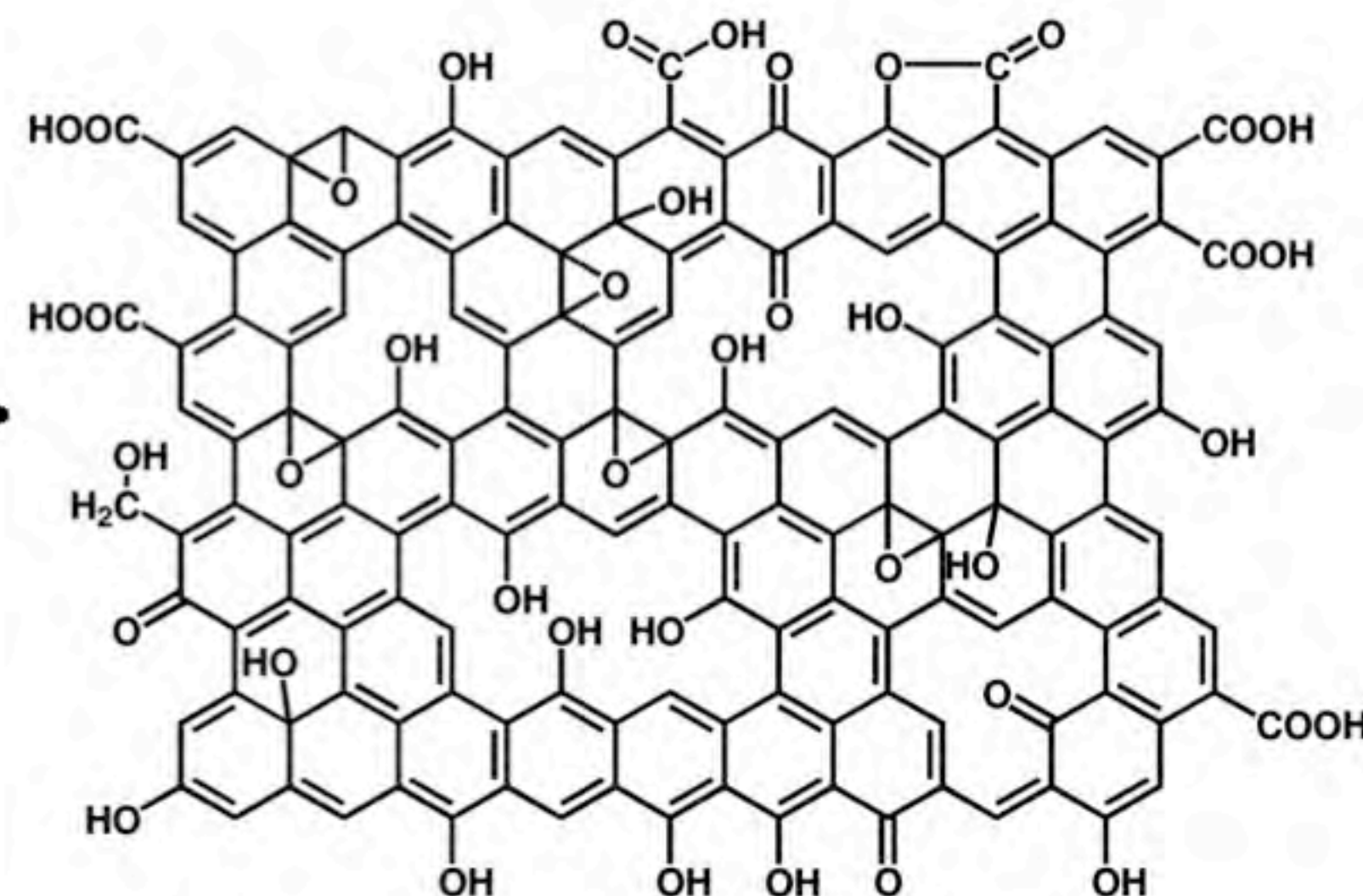
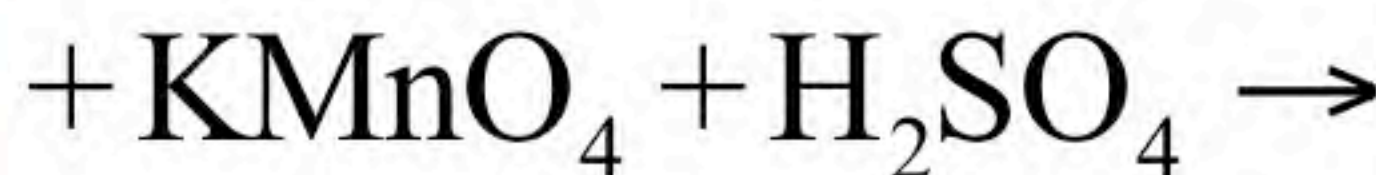
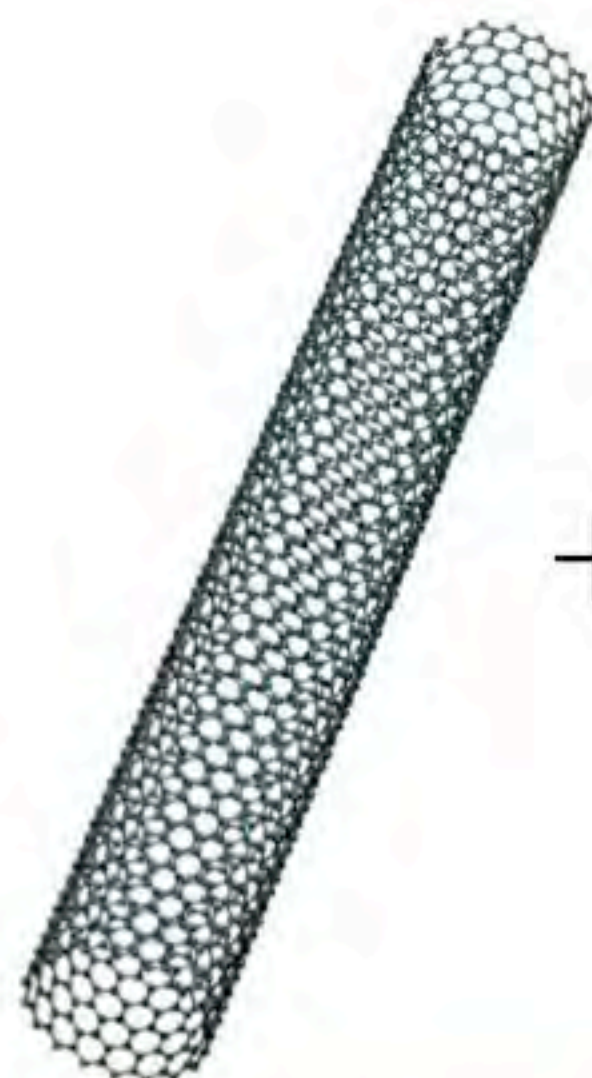
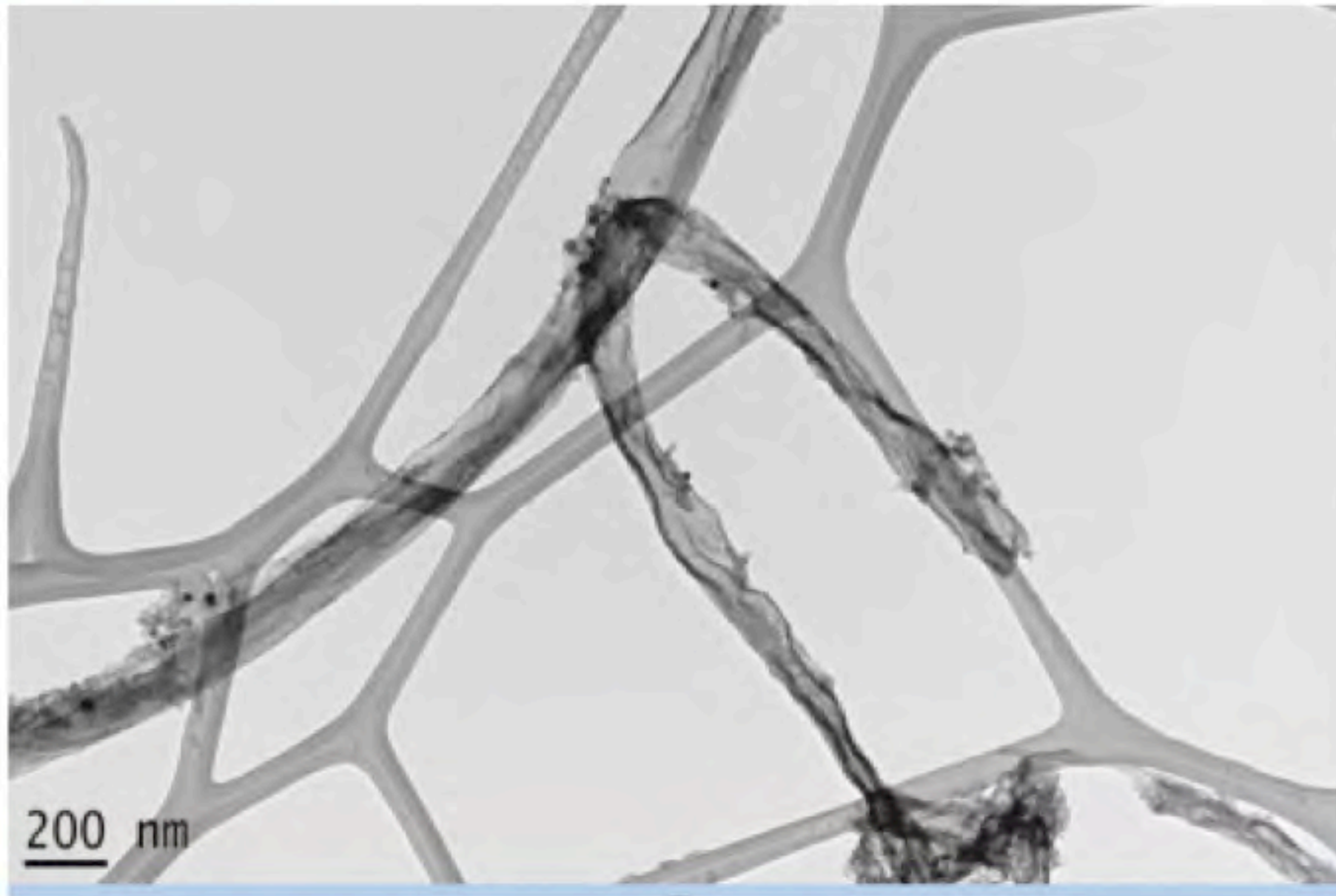


Image by Dmitry V. Kosynkin

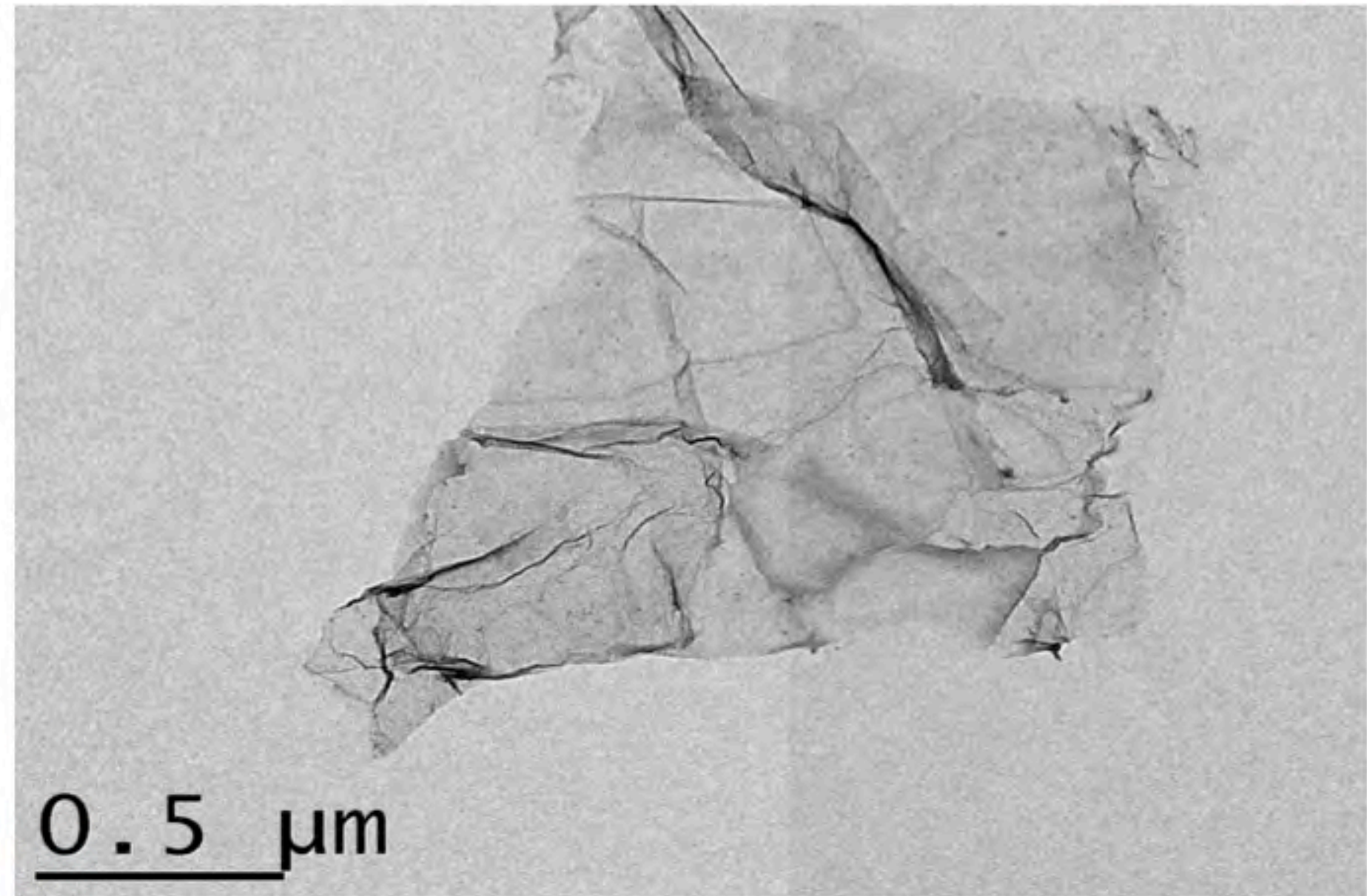
$$E_g = 2.8 - 4.2 \text{ eV}$$

J. A. Yan et al., Phys. Rev. Lett. 103 (2009) 086802

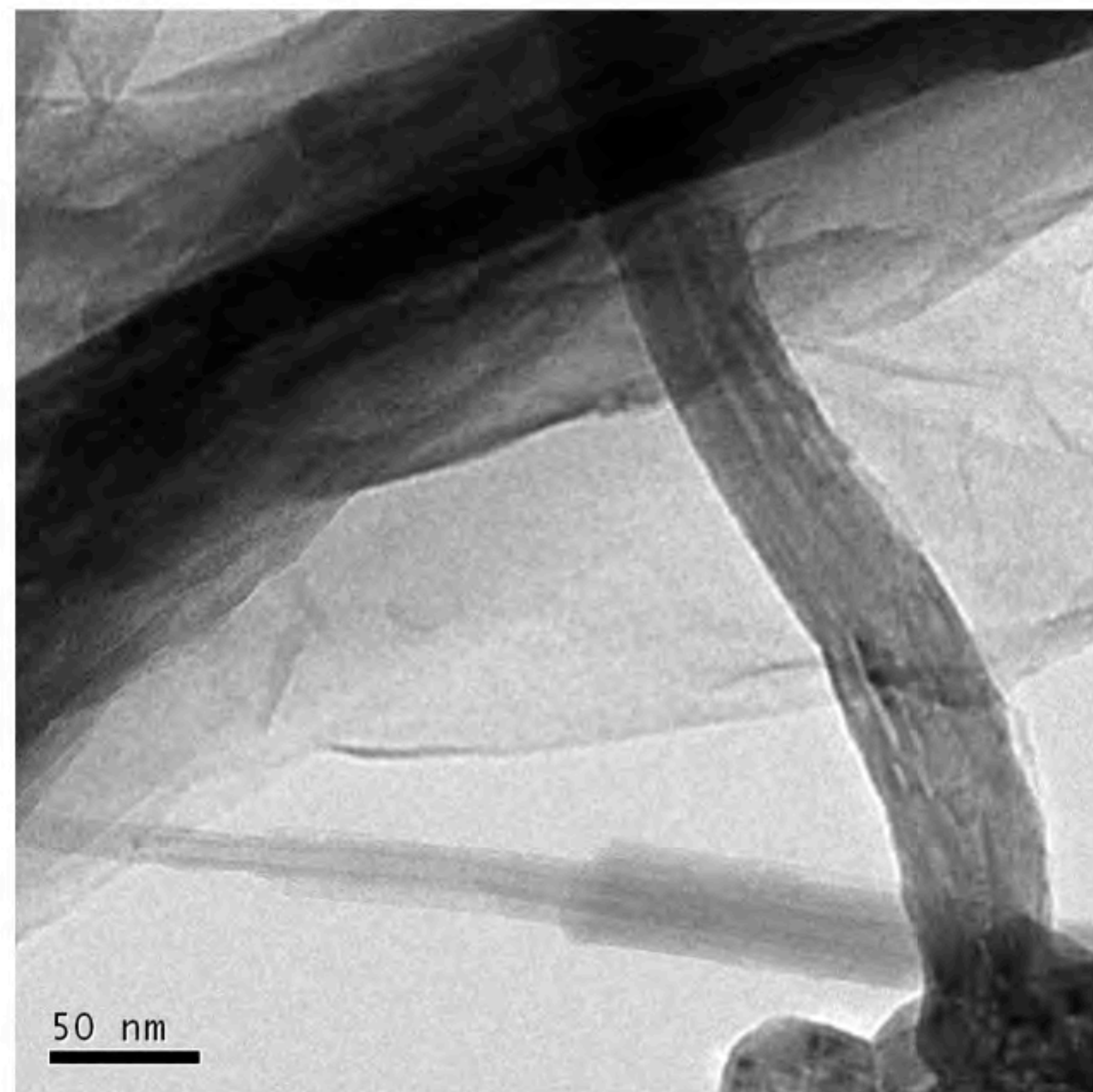
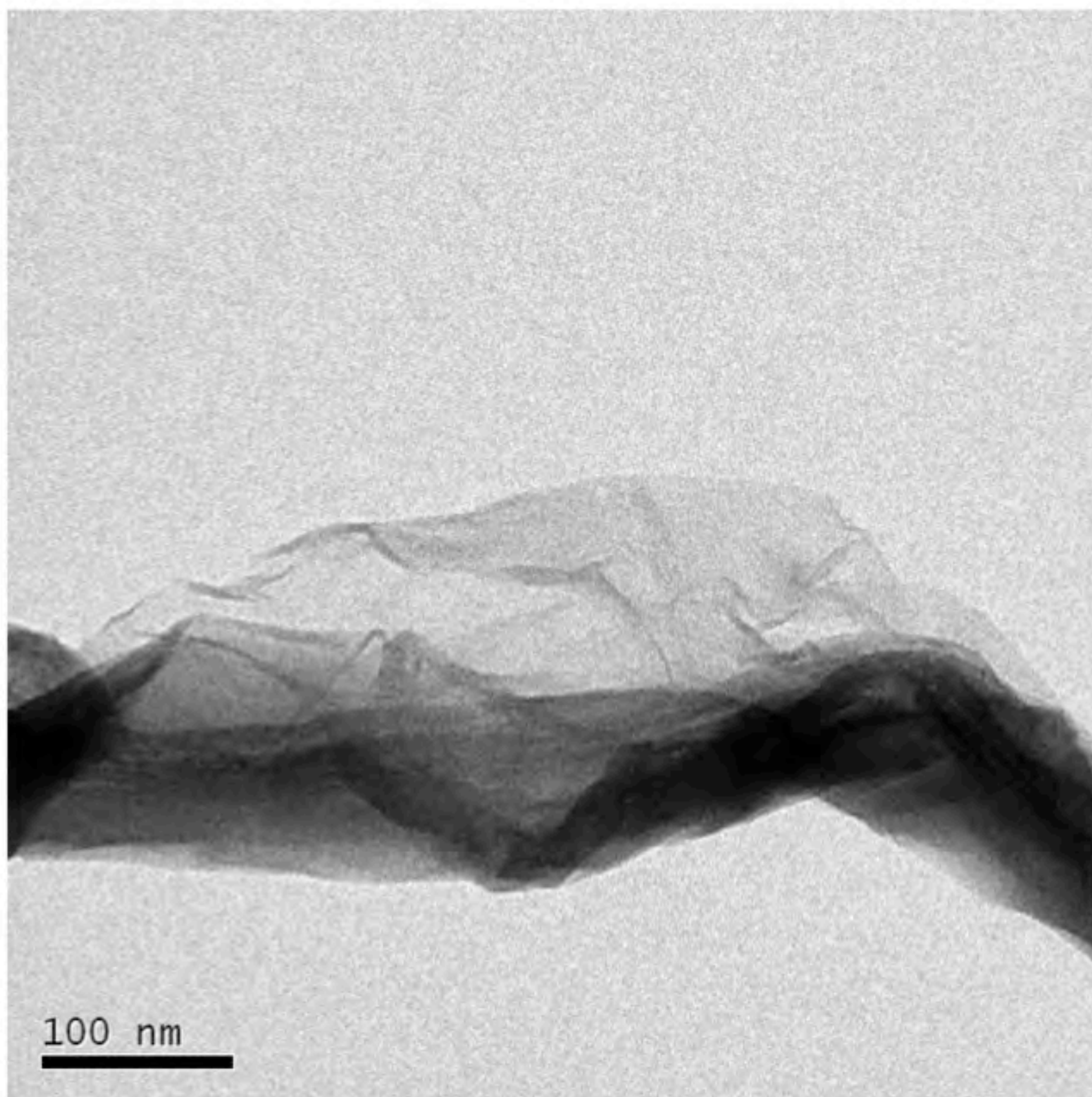
TEM images of GONR



Partially unzipped MWCNT



Warped Graphene sheet

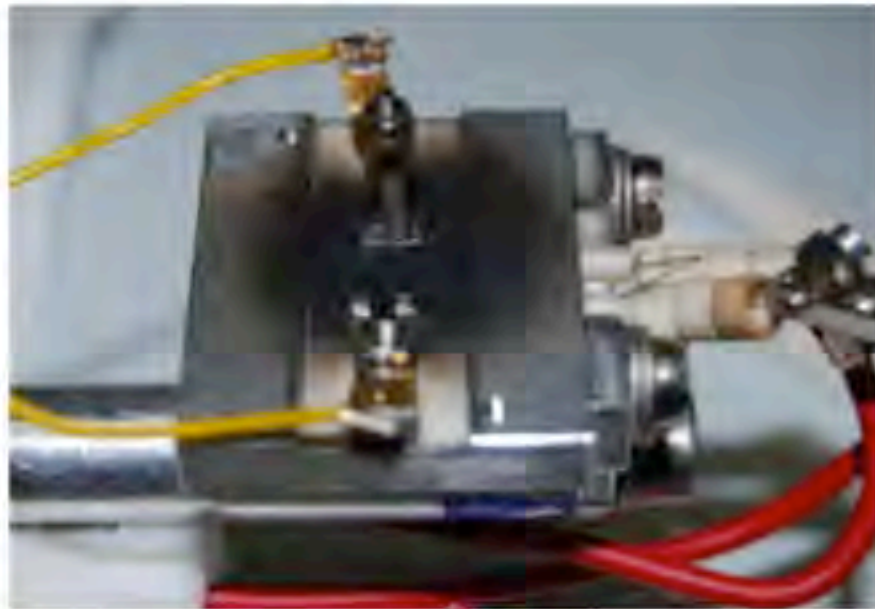


Partially peeled off carbon nanotubes

MWCNT/SWCNT deposition

Dispersion in N,N-Dimethylformamide (DMF) or o-dichlorobenzene (o-DCB) 1h in ultrasound bath (conc. 1-10 $\mu\text{g/ml}$)

Airbrush deposition on hot patterned Si substrates (200 °C)



Patterned SiO_2/Si



GONR or MWCNT suspension in DMF or o-DCB

$$\theta_C \propto \frac{1}{R_s} = \frac{W}{L} R^{-1}$$

Hot support

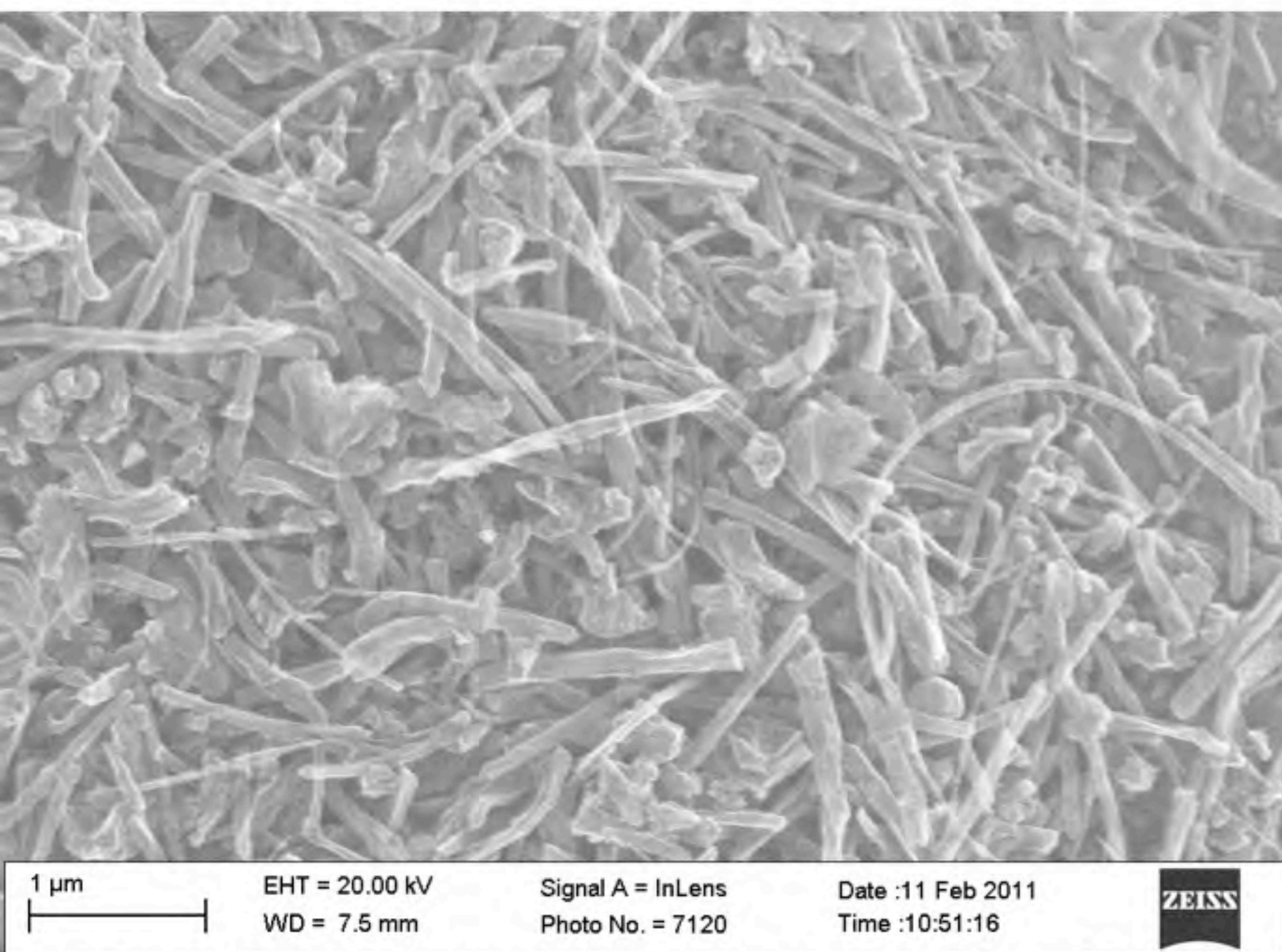
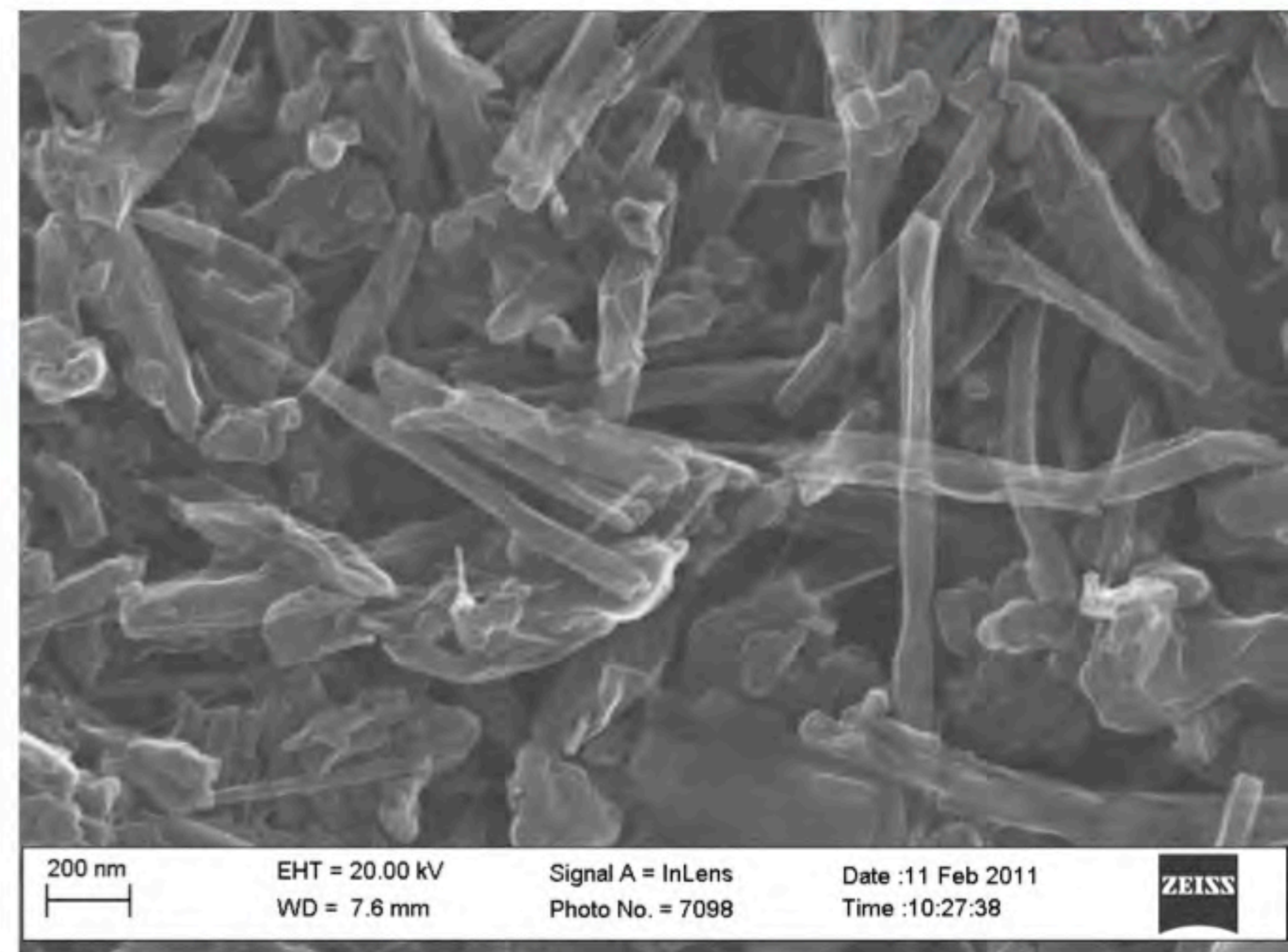
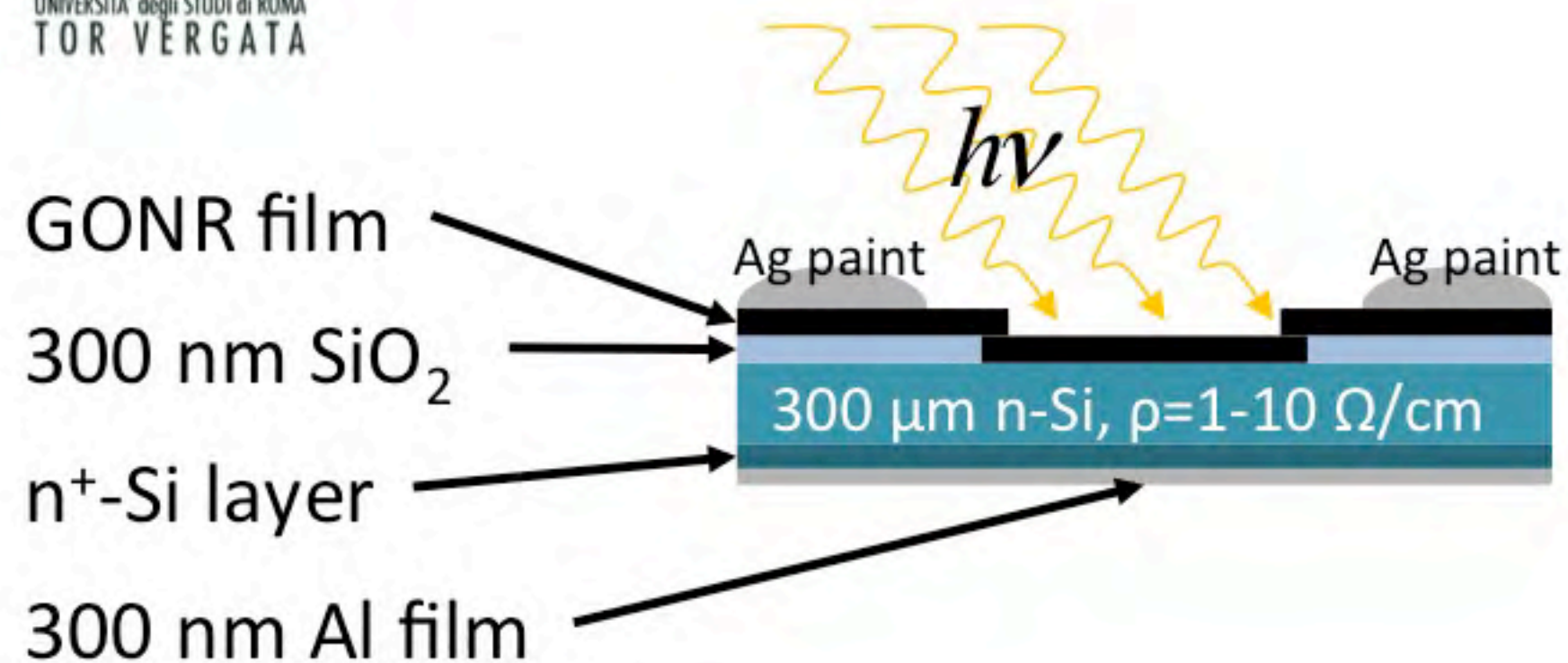
$T ; 200^\circ\text{C}$

Air brush



N_2 as gas carrier

SEM images of GONR films on Si



$$R_s = 0.8 - 1.0 \text{ M}\Omega$$





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TOR VERGATA

Labview
interface

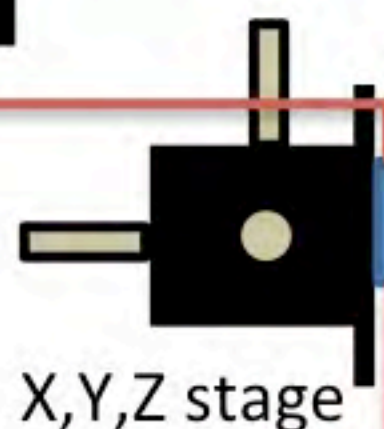
Lock-in amplifier



Low noise amplifier



Sample



X,Y,Z stage

Optical setup

amplifier

Si photodetector

Monochromator

Xe
lamp

Mirrored
chopper

Sourcimeter

PC
interface

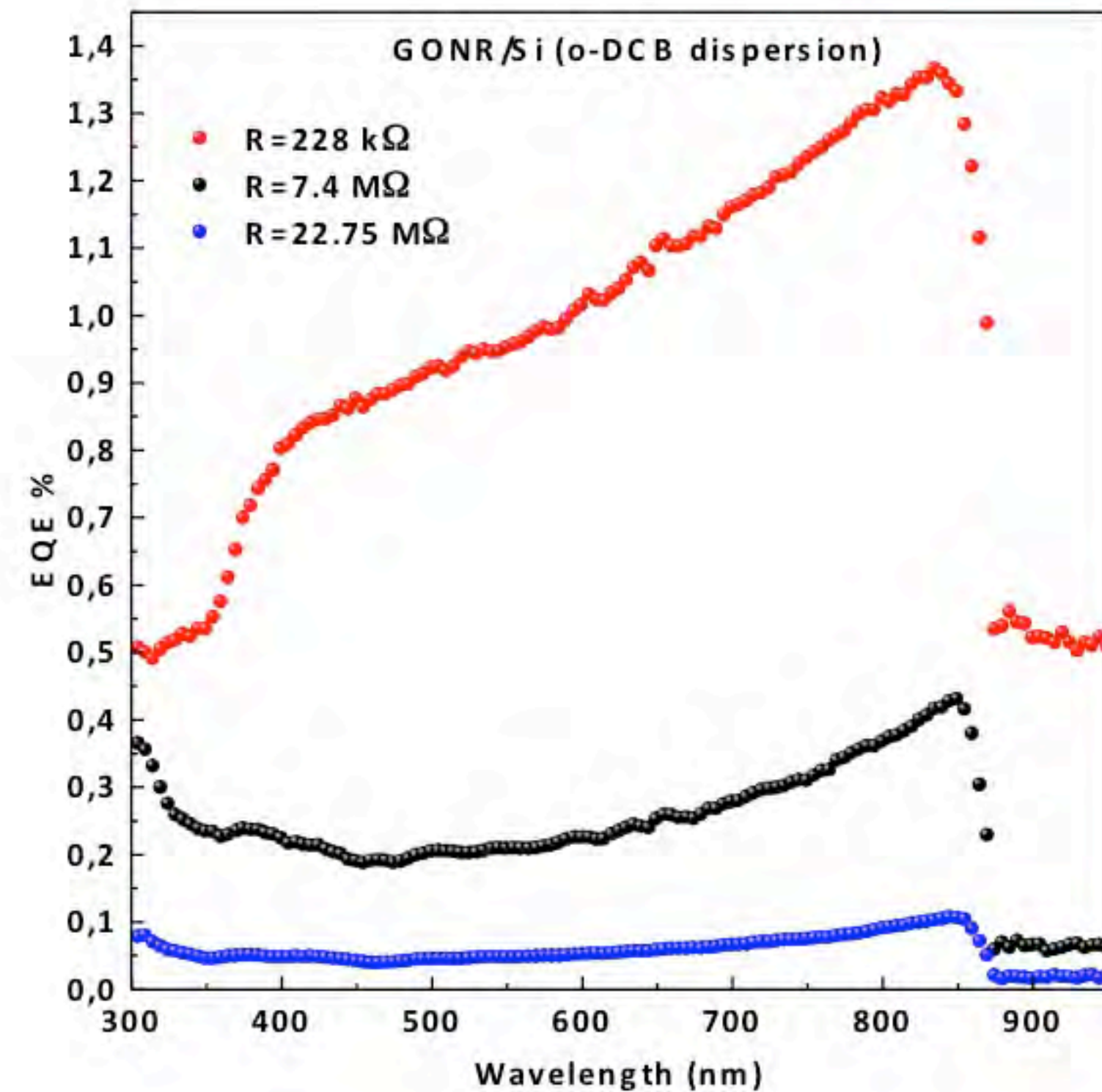
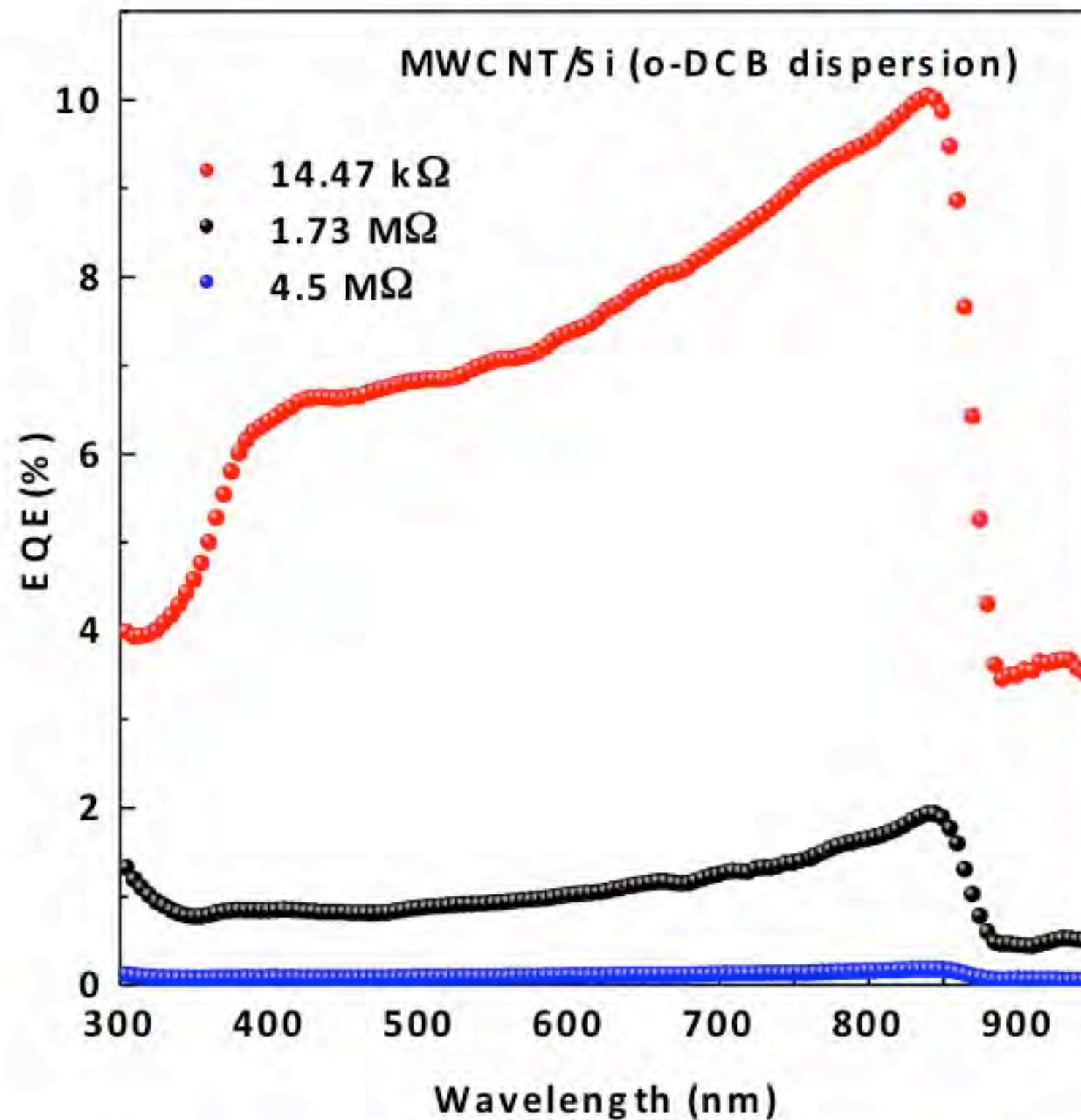


External quantum efficiency

$$EQE(\lambda) = \frac{hcI(\lambda)}{e\lambda P(\lambda)} 100$$

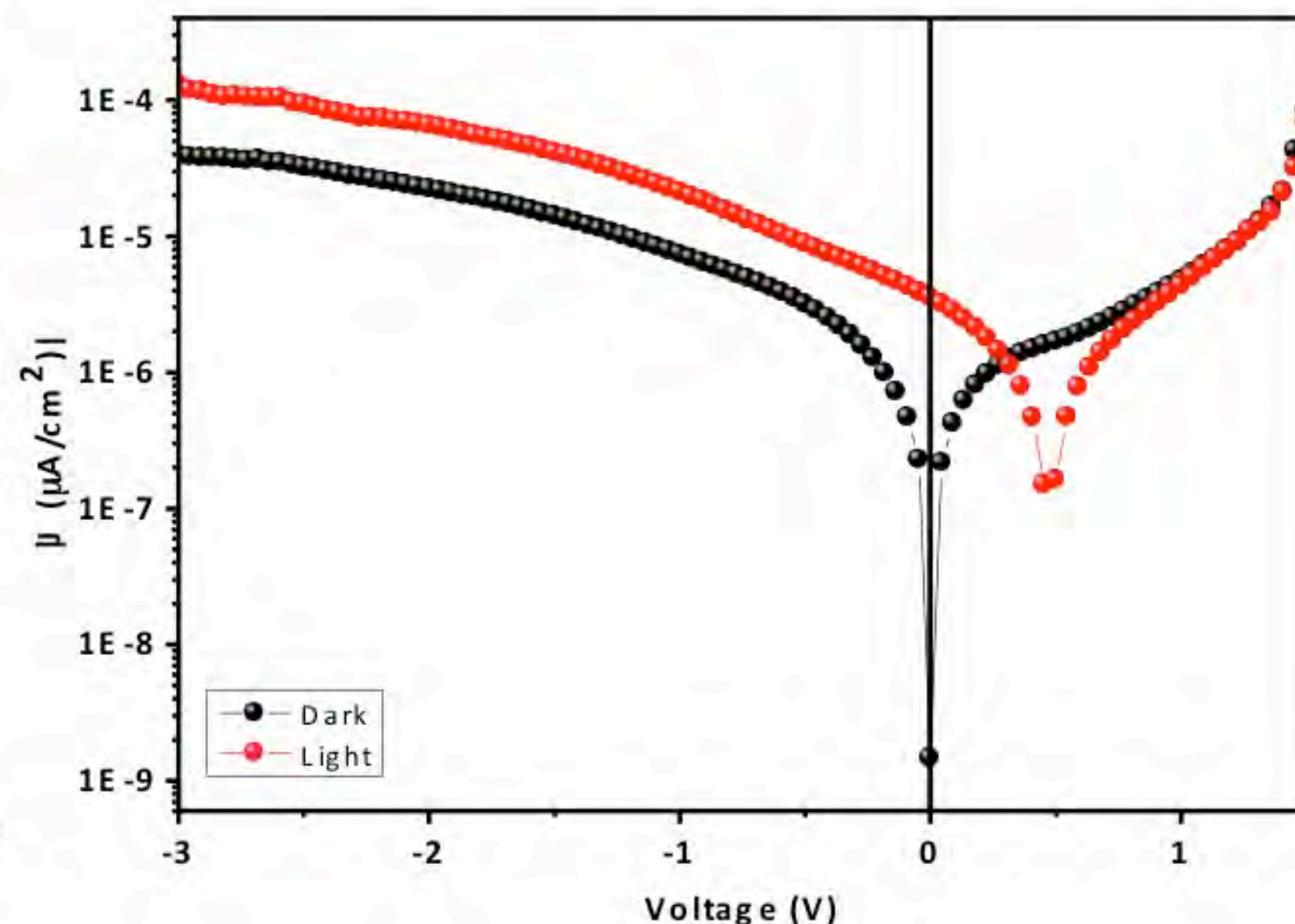
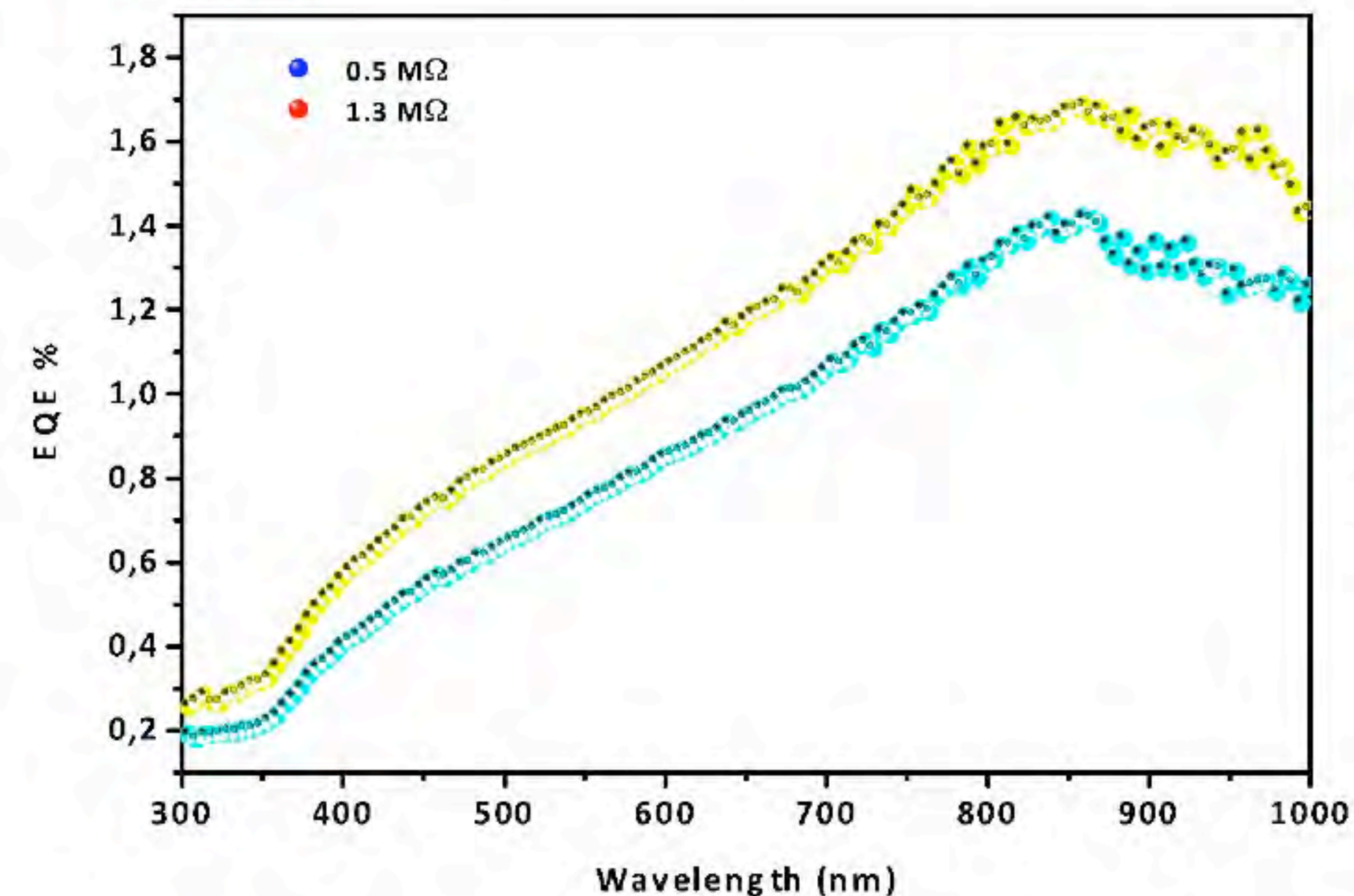


Optoelectronic characterization



Samples prepared from o-dichlorobenzene GONR and MWCNT suspensions

Optoelectronic characterization



$$EQE(\lambda) = \frac{hcI(\lambda)}{e\lambda P(\lambda)} 100$$

$$I_{SC} \approx 10^{-6} \text{ A}$$

$$V_{OC} \approx 500 \text{ mV}$$

Samples prepared from N,N-dimethylformamide GONR and MWCNT suspensions

Summary

- Graphenic nanoribbons were produced by chemical unzipping of MWCNTs
- Photovoltaic devices were realized depositing GONR and MWCNT films on Si
- Low conductivity of the GONR films negatively affects the efficiency of the cells
- Improvements of the GONR films are needed

Thank you for attention!